2018 年海外教师主导本科全英文课程

报告人: 尹友教授,日本群马大学

报告地点: 教四 309 教室

报告内容: 半导体工艺制备技术系列讲座

17th, Sep., 1. Advanced nanofabrication process-

2018 lighography

8:30-11:30am Photolighography

Electron beam lighography

Other advanced lithography technologies

21th, Sep., 2. Advanced nanofabrication process-

2018 etching

8:30-11:30am Wet chemical etching

Dry etching

Advanced etching technologies

22th, Sep. , 2018 3. Advanced memories

6pm-9pm High-performance phase-change memory

High-performance resistive random access

memory

Other advanced memory technologies

23th, Sep. , 4. Advanced solar cells

6pm-9pm High-efficiency silicon solar Cells

High-efficiency quatum dot solar cells

Other solar cell technologies

25th, Sep. , 2018 5. Advanced sensors

6pm-9pm High-sensitivity biosensor

High sensitivity gas sensor Other advanced sensors

26th, Sep. , 2018 6. Advanced CMOS process flow

6pm-9pm

欢迎同学们参加!